

<b>Electronic Patent Application Fee Transmittal</b>				
<b>Application Number:</b>	10823364			
<b>Filing Date:</b>	12-Apr-2004			
<b>Title of Invention:</b>	Plasma control using dual cathode frequency mixing			
<b>First Named Inventor/Applicant Name:</b>	Steven C. Shannon			
<b>Filer:</b>	Alan Michael Taboada			
<b>Attorney Docket Number:</b>	8756/ETCH/DICP			
Filed as Large Entity				
<b>Utility under 35 USC 111(a) Filing Fees</b>				
Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
<b>Basic Filing:</b>				
<b>Pages:</b>				
<b>Claims:</b>				
Independent claims in excess of 3	1201	2	220	440
<b>Miscellaneous-Filing:</b>				
<b>Petition:</b>				
<b>Patent-Appeals-and-Interference:</b>				
<b>Post-Allowance-and-Post-Issuance:</b>				
<b>Extension-of-Time:</b>				

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
<b>Miscellaneous:</b>				
<b>Total in USD (\$)</b>				<b>440</b>